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(71) Applicant *(for all designated States except US)*: **SEZ AG** [AT/AT]; Draubodenweg 29, A-9500 Villach (AT).

(72) Inventor; and

(75) Inventor/Applicant *(for US only)*: **OKORN-SCHMIDT, Harald** [AT/AT]; Gerlitzenweg 1, A-9020 Klagenfurt (AT).

(74) Agent: **KONTRUS, Gerhard**; c/o SEZ AG, Draubodenweg 29, A-9500 Villach (AT).

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— *as to the applicant's entitlement to claim the priority of the earlier application (Rule 4.17(iii))*

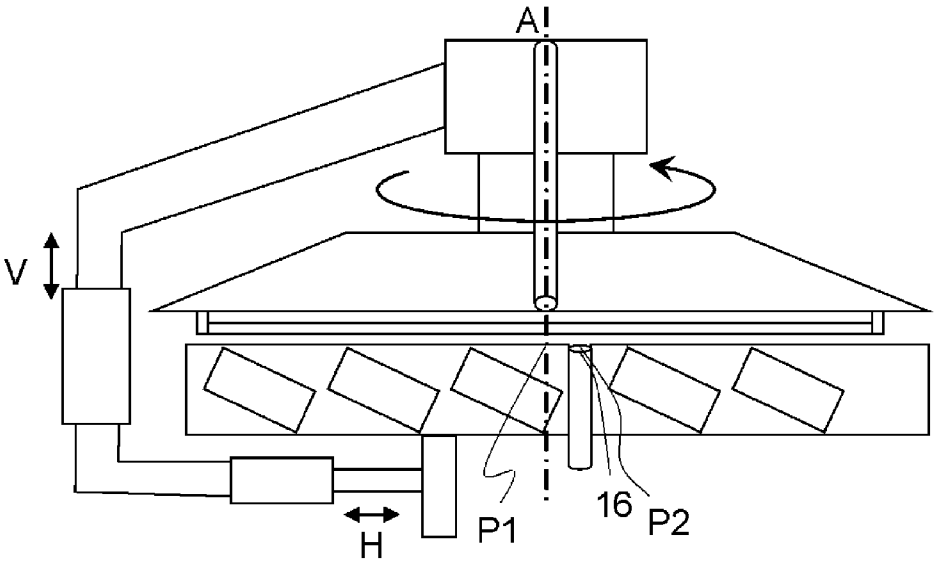
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(54) Title: APPARATUS METHOD FOR WET TREATMENT OF WAFERS




(57) Abstract: Disclosed is a device for wet treatment of disk-like substrates comprising a first plate (10) with a size and shape being able to overlap a disk-like substrate to be treated, holding means (22) for holding a disk-like substrate (W) parallel to said first plate in a distance of 0.2 to 5 mm, rotating means (37) for rotating the disk-like substrate (W) about a rotation axis (A) substantially perpendicular to said first plate, first dispensing means (14) with a first dispensing opening (16) in the first gap for introducing fluid into a first gap (11) between said first plate (10) and a disk-like substrate (W) when being treated, and shifting means (34) for shifting the position of said first dispensing opening (16) from a first position (P1) to a second position (P2) wherein the distance of said first position (P1) to the rotation axis (A) is smaller than the distance of said second position (P2) to the rotation axis (A). Furthermore an associated method is disclosed.

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